

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Patent Application of:

Koji SHIGEMURA

Application No.:

Group Art Unit:

Filed: November 21, 2003

Examiner:

For: DEPOSITION MASK FRAME ASSEMBLY, METHOD OF FABRICATING THE SAME, AND METHOD OF FABRICATING ORGANIC ELECTROLUMINESCENT DEVICE USING THE DEPOSITION MASK FRAME ASSEMBLY

**INFORMATION DISCLOSURE STATEMENT**

Commissioner for Patents  
PO Box 1450  
Alexandria, VA 22313-1450

Sir:

In accordance with the duty of disclosure provisions of 37 CFR § 1.56, there is hereby provided certain information which the Examiner may consider material to the examination of the subject U.S. patent application. It is requested that the Examiner make this information of record if it is deemed material to the examination of the subject application.

1. Enclosures accompanying this Information Disclosure Statement are:

- 1a. ☒ Form PTO-1449.
- 1b. ☒ Copies of IDS citations.
- 1c. ☐ An English language copy of search report(s) from a counterpart foreign application or a PCT International Search Report.
- 1d. ☐ English language translation (complete or relevant portion(s)) attached to each non-English language publication.
- 1e. ☒ Explanations of Relevancy of References (ATTACHMENT 1(e), hereto) for providing a concise explanation of each non-English publication.

2. ☐ In accordance with 37 CFR § 1.98, a concise explanation of what is presently understood to be the relevance of each non-English language publication is

(Check appropriate Items 2a, 2b, 2c and/or 2d)

- 2a. ☐ satisfied because all non-English language publications were cited on the enclosed "English-language version of the search report or action which indicates the degree of relevance found by the foreign office". (See MPEP 609, Minimum Requirements for an Information Disclosure Statement, Part A(3): Concise Explanation of Relevance, pp. 600-100 to 600-101, Rev. 1, Feb. 2000.)
- 2b. ☐ set forth in the application.

- 2c. ☐ satisfied because an English language translation (complete or relevant portion(s)) is attached to each non-English language publication.
- 2d. ☐ enclosed as Attachment 1(e), hereto.
3. No admission is made that the information cited in this Statement is, or is considered to be, material to patentability nor a representation that a search has been made (other than search report(s) from a counterpart foreign application or a PCT International Search Report, if submitted herewith). 37 CFR §§ 1.97(g) and (h).

Respectfully submitted,

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FORM PTO-1449	U.S. DEPARTMENT OF COMMERCE PATENT AND TRADEMARK OFFICE	ATTORNEY DOCKET NO. 1670.1020	APPLICATION NO.
<b>LIST OF REFERENCES CITED BY APPLICANT</b>  <i>(Use several sheets if necessary)</i>		FIRST NAMED INVENTOR Koji SHIGEMURA	
		FILING DATE November 20, 2003	GROUP ART UNIT

### U.S. PATENT DOCUMENTS

EXAMINER INITIAL	DOCUMENT NO.	DATE	NAME	CLASS	SUB-CLASS	FILING DATE
AA						
AB						
AC						

### FOREIGN PATENT DOCUMENTS

	EXAMINER INITIAL	DOCUMENT NO.	DATE	COUNTRY	CLASS	SUB-CLASS	TRANSLATION	
							YES	NO
	AG	2000-48954	2-18-00	Japan				X
	AH	2000-173769	6-23-00	Japan				X
	AI	2001-110567	4-20-01	Japan				X
	AJ	2001-203079	7-27-01	Japan				X
	AK	2001-247961	9-14-01	Japan				X
	AL	2001-254169	9-18-01	Japan				X
	AM	2001-273979	10-5-01	Japan				X
	AN	2002-8859	1-11-02	Japan				X
	AO	2002-9098	1-11-02	Japan				X
	AP							

### OTHER REFERENCES (INCLUDING AUTHOR, TITLE, DATE, PERTINENT PAGES, ETC.)

	AM	
	AN	
	AO	

EXAMINER	DATE CONSIDERED
<small>EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.</small>	

<b>EXPLANATIONS OF RELEVANCY OF REFERENCES</b>	ATTORNEY DOCKET NO. 1670.1020	APPLICATION NO.
	FIRST NAMED INVENTOR Koji SHIGEMURA	
	FILING DATE November 21, 2003	GROUP ART UNIT

Reference AG: Japanese Patent No. 2000-48954 published 2-18-00 is generally related to "DEPOSITION MASK FRAME ASSEMBLY, METHOD OF FABRICATING THE SAME, AND METHOD OF FABRICATING ORGANIC ELECTROLUMINESCENT DEVICE USING THE DEPOSITION MASK FRAME ASSEMBLY.

Reference AH: Japanese Patent No. 2000-173769 published 6-23-00 is generally related to "DEPOSITION MASK FRAME ASSEMBLY, METHOD OF FABRICATING THE SAME, AND METHOD OF FABRICATING ORGANIC ELECTROLUMINESCENT DEVICE USING THE DEPOSITION MASK FRAME ASSEMBLY.

Reference AI: Japanese Patent No. 2001-110567 published 4-20-01 is generally related to "DEPOSITION MASK FRAME ASSEMBLY, METHOD OF FABRICATING THE SAME, AND METHOD OF FABRICATING ORGANIC ELECTROLUMINESCENT DEVICE USING THE DEPOSITION MASK FRAME ASSEMBLY.

Reference AJ: Japanese Patent No. 2001-203079 published 7-27-01 is generally related to "DEPOSITION MASK FRAME ASSEMBLY, METHOD OF FABRICATING THE SAME, AND METHOD OF FABRICATING ORGANIC ELECTROLUMINESCENT DEVICE USING THE DEPOSITION MASK FRAME ASSEMBLY.

Reference AK: Japanese Patent No. 2001-247961 published 9-14-01 is generally related to "DEPOSITION MASK FRAME ASSEMBLY, METHOD OF FABRICATING THE SAME, AND METHOD OF FABRICATING ORGANIC ELECTROLUMINESCENT DEVICE USING THE DEPOSITION MASK FRAME ASSEMBLY.

Reference AL: Japanese Patent No. 2001-254169 published 9-18-01 is generally related to "DEPOSITION MASK FRAME ASSEMBLY, METHOD OF FABRICATING THE SAME, AND METHOD OF FABRICATING ORGANIC ELECTROLUMINESCENT DEVICE USING THE DEPOSITION MASK FRAME ASSEMBLY.

Reference AM: Japanese Patent No. 2001-273979 published 10-5-01 is generally related to "DEPOSITION MASK FRAME ASSEMBLY, METHOD OF FABRICATING THE SAME, AND METHOD OF FABRICATING ORGANIC ELECTROLUMINESCENT DEVICE USING THE DEPOSITION MASK FRAME ASSEMBLY.

Reference AN: Japanese Patent No. 2002-8859 published 1-11-02 is generally related to "DEPOSITION MASK FRAME ASSEMBLY, METHOD OF FABRICATING THE SAME, AND METHOD OF FABRICATING ORGANIC ELECTROLUMINESCENT DEVICE USING THE DEPOSITION MASK FRAME ASSEMBLY.

Reference AO: Japanese Patent No. 2002-9098 published 1-11-02 is generally related to "DEPOSITION MASK FRAME ASSEMBLY, METHOD OF FABRICATING THE SAME, AND METHOD OF FABRICATING ORGANIC ELECTROLUMINESCENT DEVICE USING THE DEPOSITION MASK FRAME ASSEMBLY.